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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/672,769	09/26/2003	Han-Ti Hsiaw	67,200-1159	9707
7590 09/14/2004			EXAMINER	
TUNG & ASSOCIATES Suite 120 838 W. Long Lake Road Bloomfield Hills, MI 48302			NHU, DAVID	
			ART UNIT	PAPER NUMBER
			2818	
		DATE MAILED: 09/14/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

. <u> </u>					
	Application No.	Applicant(s)			
0.00	10/672,769	HSIAW ET AL.			
Office Action Summary	Examiner	Art Unit			
	David Nhu	2818			
The MAILING DATE of this communication appeariod for Reply	ppears on the cover sheet with the	correspondence address			
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory perio - Failure to reply within the set or extended period for reply will, by statu. Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	.136(a). In no event, however, may a reply be tile ply within the statutory minimum of thirty (30) daily d will apply and will expire SIX (6) MONTHS from the, cause the application to become ABANDONE	mely filed ys will be considered timely. the mailing date of this communication. ED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 26	September 2003.				
2a) ☐ This action is FINAL . 2b) ☑ Th	is action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) ⊠ Claim(s) 1-28 is/are pending in the application 4a) Of the above claim(s) is/are withdrest signal is/are allowed. 5) □ Claim(s) is/are allowed. 6) □ Claim(s) is/are rejected. 7) □ Claim(s) is/are objected to. 8) ⊠ Claim(s) 1-28 are subject to restriction and/or	awn from consideration.				
Application Papers					
9)☐ The specification is objected to by the Examiner.					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document of the priority document of the priority document of the certified copies of	nts have been received. nts have been received in Applicat iority documents have been receiv	ion No			
* See the attached detailed Office action for a list of the certified copies not received.					
	Dui				
Attachment(s)	4) 🔲 Interview Summary	· · (PTO 413)			
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/06 Paper No(s)/Mail Date 	Paper No(s)/Mail D				

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Election/Restrictions

1. Restriction to one of the following inventions is required under 35 U.S.C. 121:

Group I: Claims 1-23, draw to a method of forming an ILD dielectric layer stack to allow improved local interconnect formation and to allow improved control over thickness and reduced metallic residue, classified in class 438, and subclass 197

Group II: Claim 24-28, draw to a local interconnect (IL) dielectric stack, classified 257, and subclass 288.

- 2. Inventions I and II are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case unpatentability of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by the processes /method materially different from those of the group II invention. For example, in claim 1, depositing a second layer of undoped SiO2 over and contacting the first layer to a thickness sufficient to leave a second layer thickness portion overlying the first layer following a subsequently oxide CMP planarization process.
- 3. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 4. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the

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application. Any amendment of inventorship must be accompanied by a petition under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

5. Any inquiry concerning this communication on earlier communications from the examiner should be directed to David Nhu, (571)272-1792. The examiner can normally be reached on Monday-Friday from 7:30 AM to 5:00 PM.

The examiner's supervisor, David Nelms can be reached on (571)272-1787.

The fax phone number for the organization where this application or proceeding is assigned is (703)872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956

Dai Rom

David Nhu 🏖

September 9, 2004